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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Shu-Hui CHEN et al. Confirmation No: 3092
Appl. No. : 10/822,650
Filed : April 13, 2004
Title : MICROFLUIDIC CHIP SYSTEM INTEGRATED WITH NANO-ELECTROSPRAY INTERFACE AND METHOD USING THEREOF

TC/A.U. : 1797
Examiner : B. R. Gordon

Docket No.: : CHEN3656/REF
Customer No: : 23364

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This is in response to the Official Action of November 5, 2007, in connection with the above identified application. This response is timely filed.

The Official Action is a restriction requirement in which it is urged that there are two separate and distinct inventions claimed in this application. Applicants elect the Group I invention which includes claims 1-11, without traverse. Applicants reserve the right to file one or more divisional applications on the non-elected inventions at a later time.

In view of the election of the Group I invention, without traverse, an early and favorable action on the merits is now believed to be in order and is most respectfully requested.

Respectfully submitted,
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Response to RR.wpd
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